

US00D694494S

(12) **United States Design Patent**
Jacquart Thorsen et al.

(10) **Patent No.:** **US D694,494 S**

(45) **Date of Patent:** **** *Dec. 3, 2013**

(54) **HAT WITH OFFSET BADGE**

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(*) Notice: This patent is subject to a terminal disclaimer.

(**) Term: **14 Years**

(21) Appl. No.: **29/447,866**

(22) Filed: **Mar. 7, 2013**

(51) **LOC (9) Cl.** **02-03**

(52) **U.S. Cl.**
USPC **D2/882**

(58) **Field of Classification Search**
USPC D2/865, 866, 878, 879, 880, 881, 882,
D2/883, 884, 886, 891, 892, 893, 894,
D2/895; D11/95; D20/19, 27; 2/10, 12, 68,
2/171, 175.1, 175.2, 175.3, 183, 195.1,
2/195.2, 195.3, 195.4, 195.5, 195.6,
2/200.1, 200.2, 209.11, 209.12, 209.13,
2/209.7, 244; 24/305, 620; 40/1.5, 329,
40/662, 663

See application file for complete search history.

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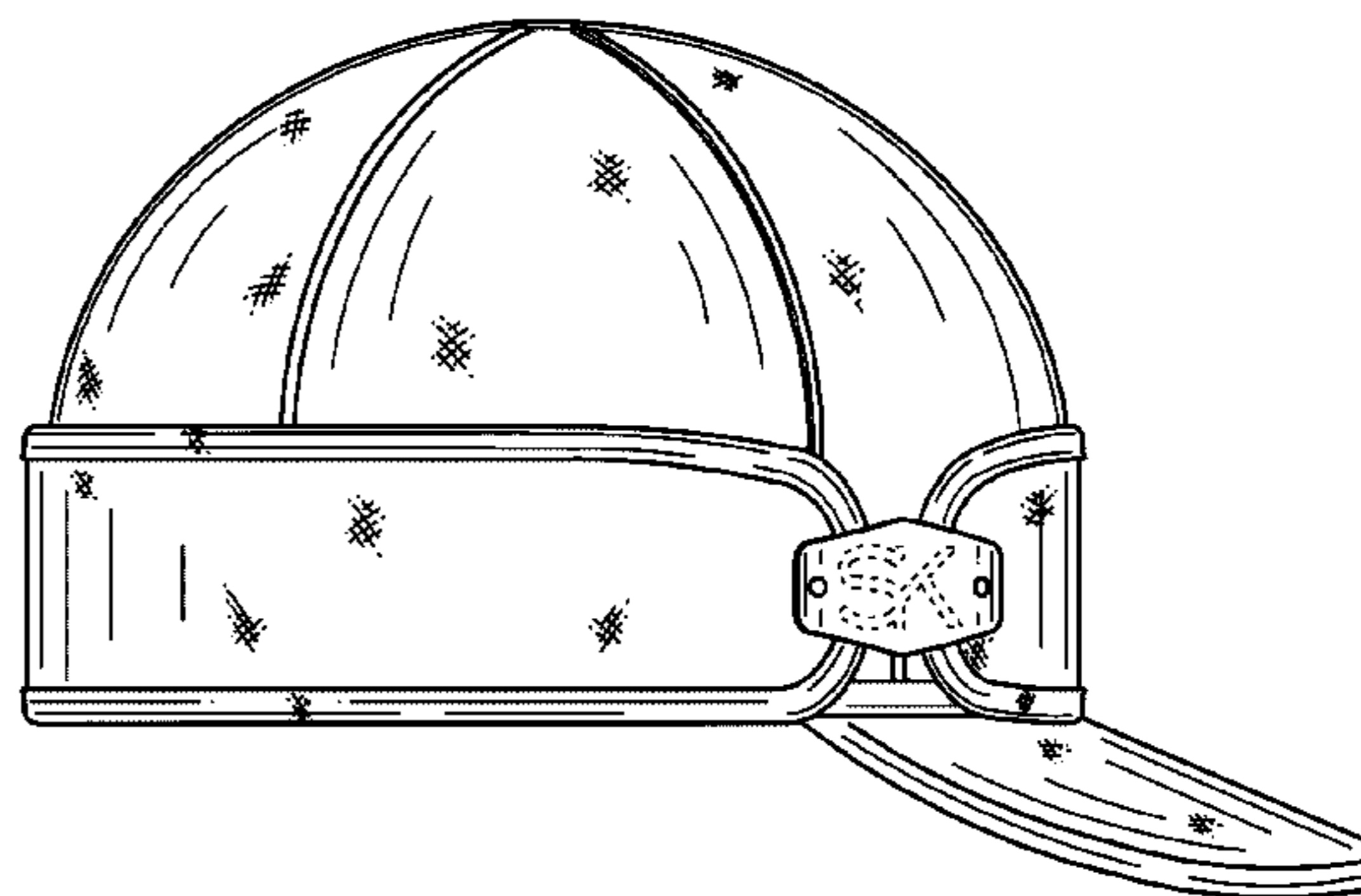
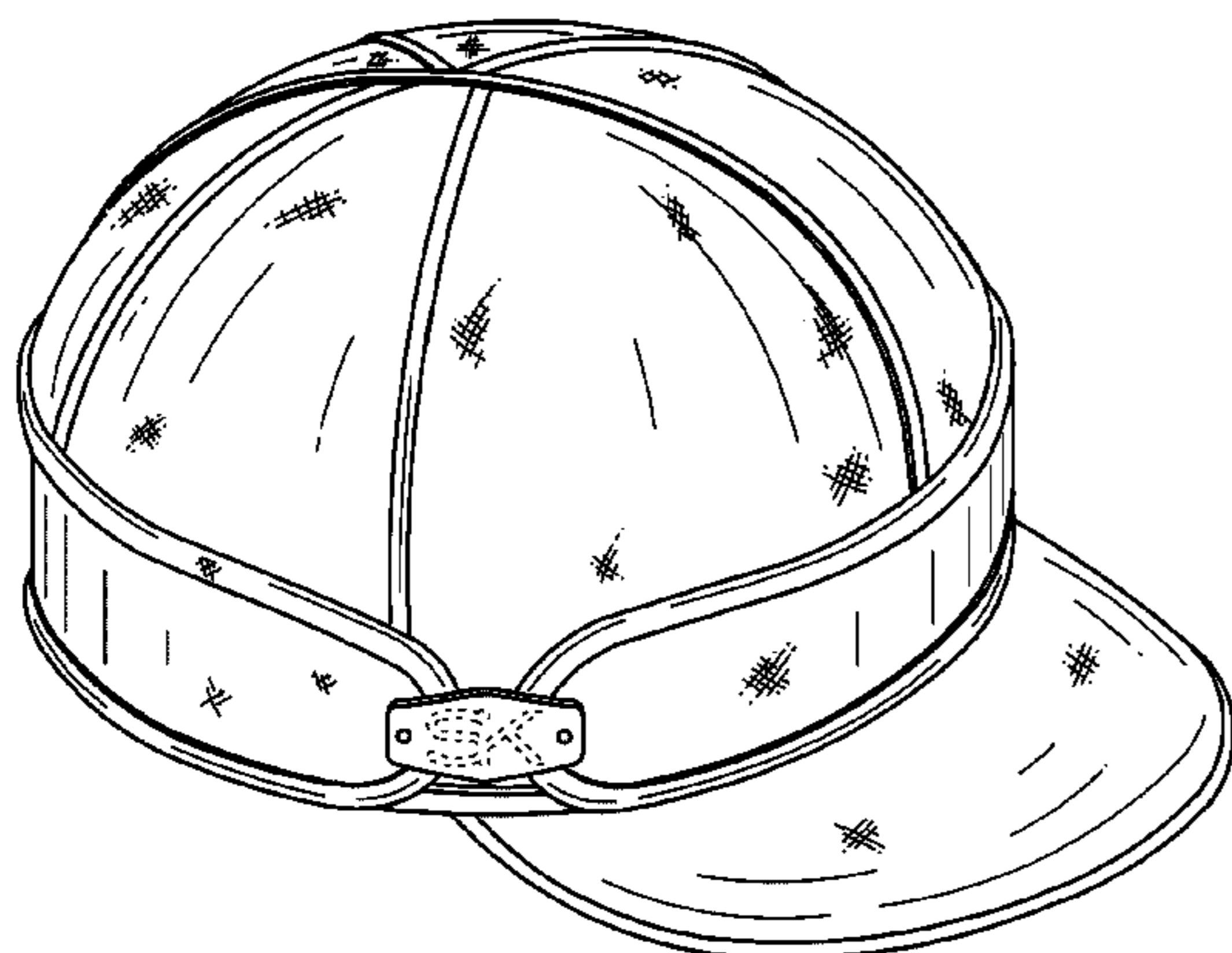
(57) **CLAIM**

The ornamental design for a hat with an offset badge, as shown and described.

DESCRIPTION

FIG. 1 is an isometric view of a hat with a badge;
FIG. 2 is a right side elevation view of the hat with badge;
FIG. 3 is a front elevation view of the hat with badge;
FIG. 4 is a left side elevation view of the hat with badge;
FIG. 5 is a back elevation view of the hat with badge;
FIG. 6 is a top plan view of the hat with badge; and,
FIG. 7 is a bottom plan view of the hat with badge.
The letters SK shown in broken lines in the Figures are unclaimed features of the article to which the design is applied.

1 Claim, 4 Drawing Sheets



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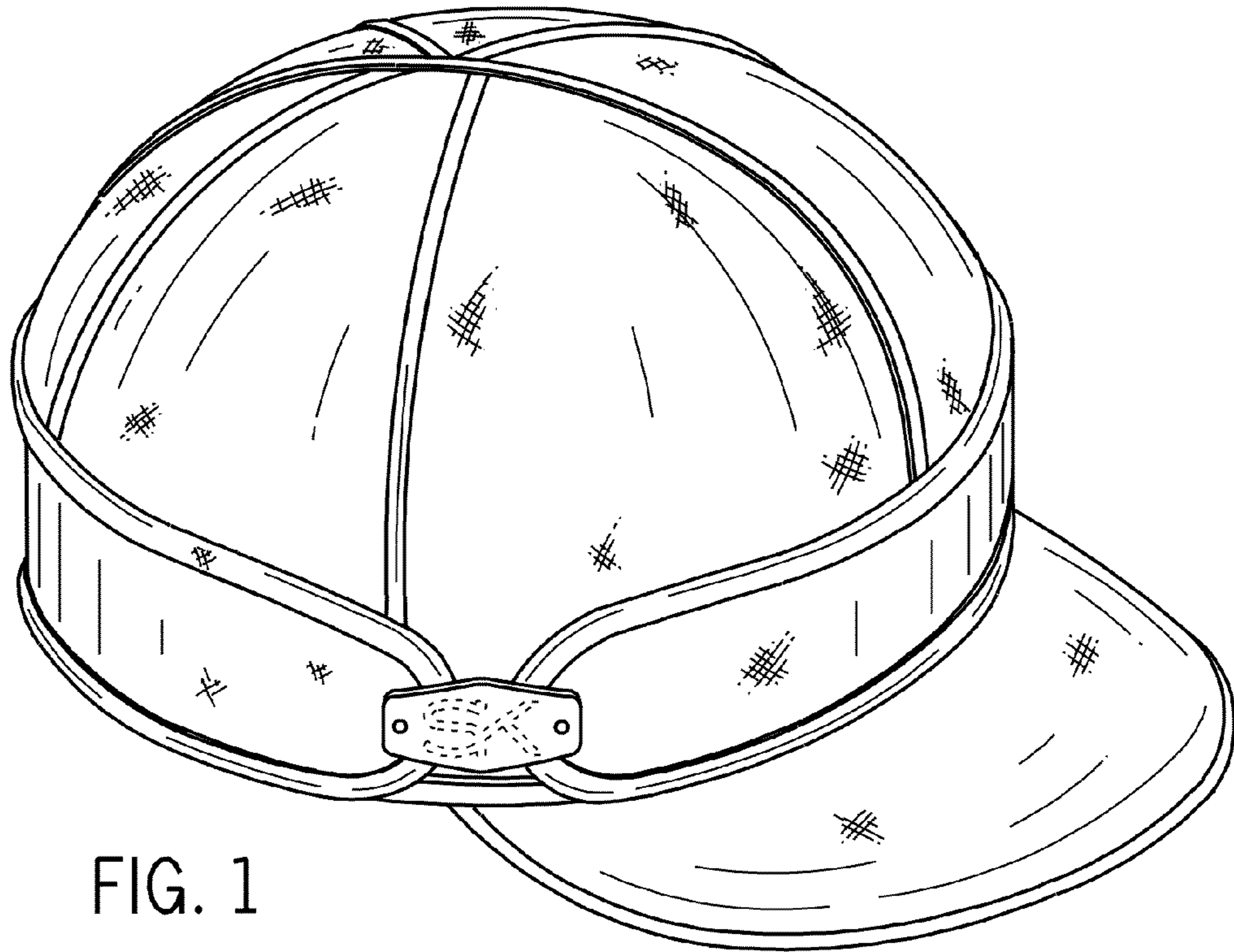


FIG. 1

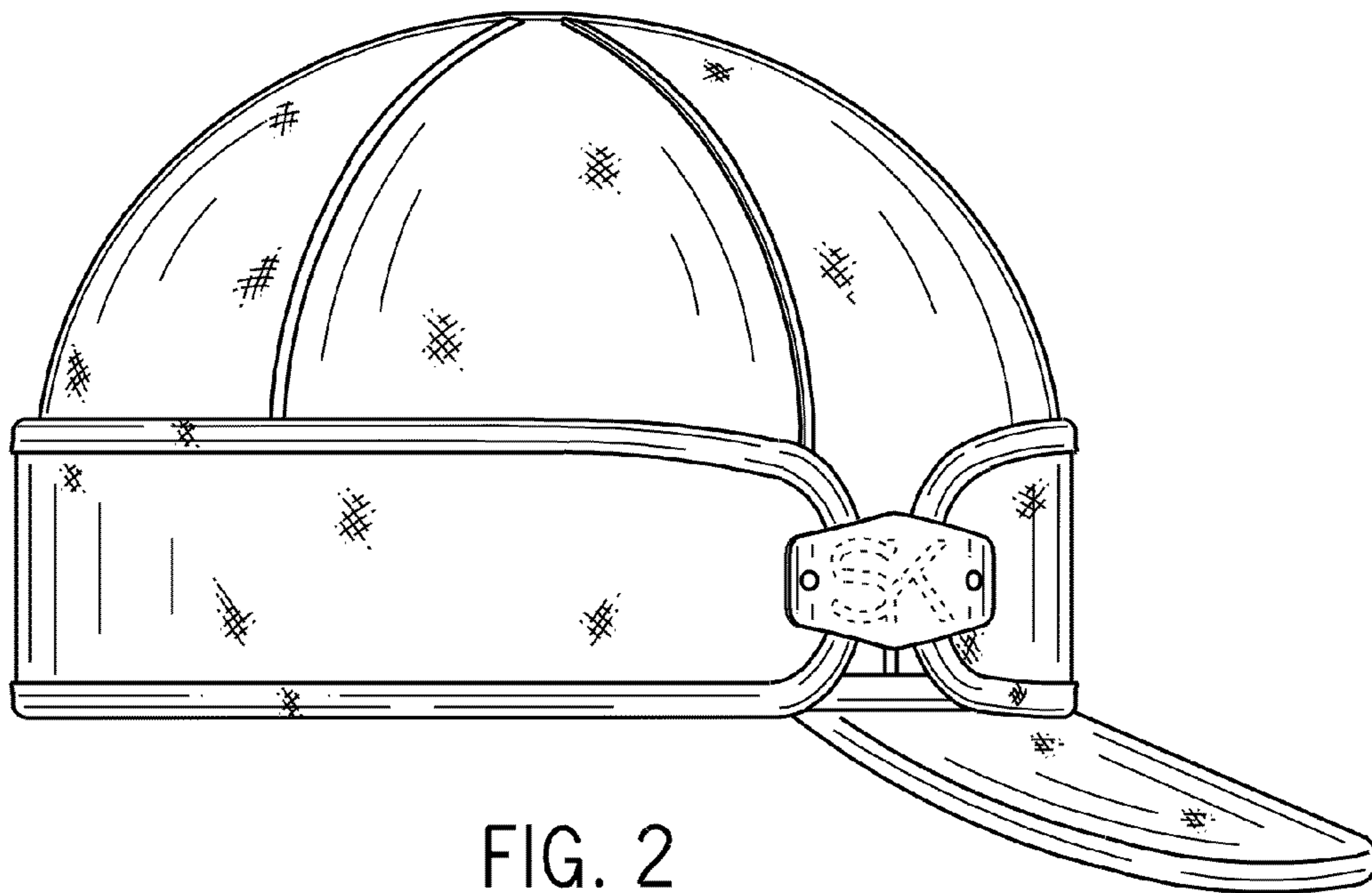


FIG. 2

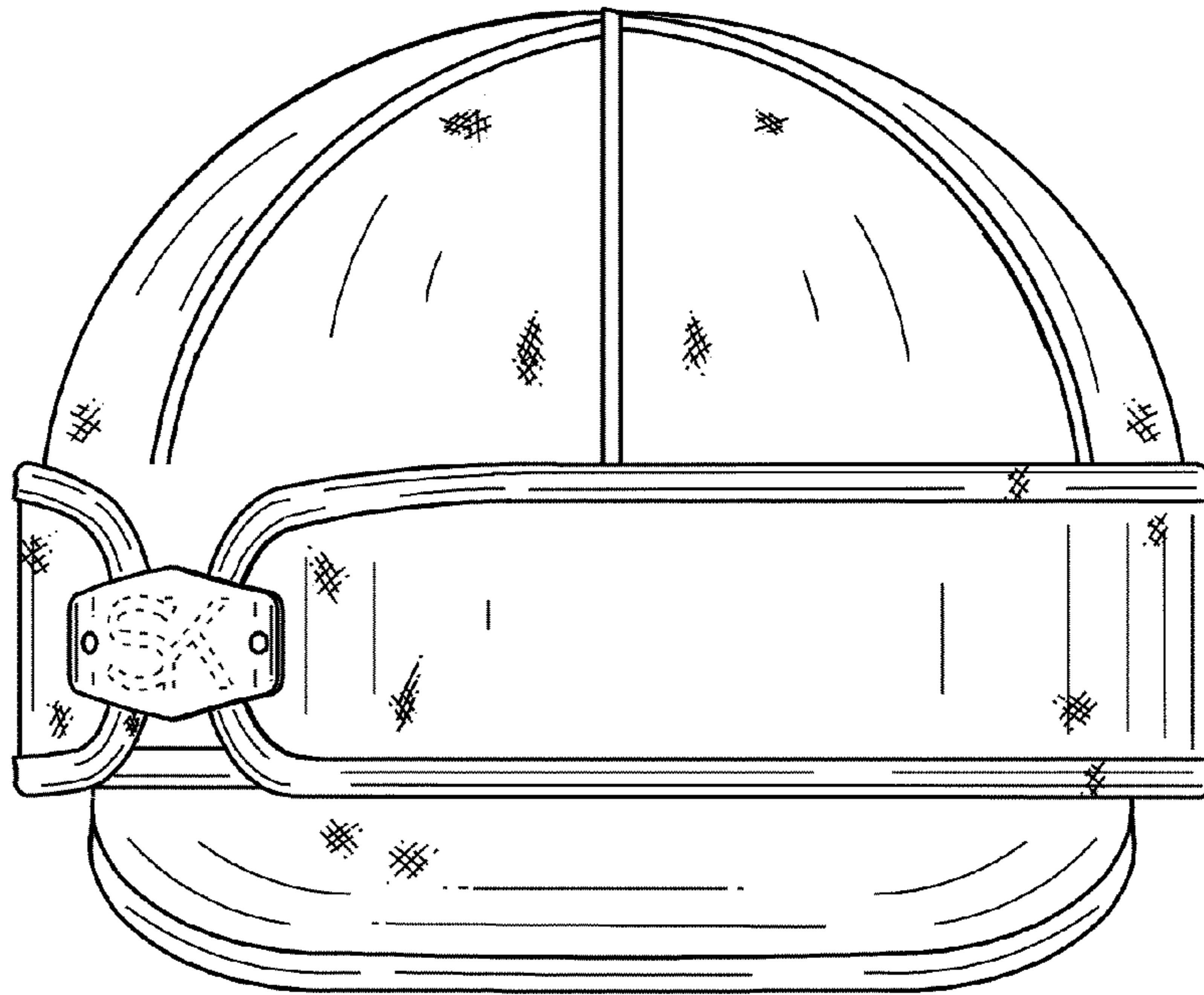


FIG. 3

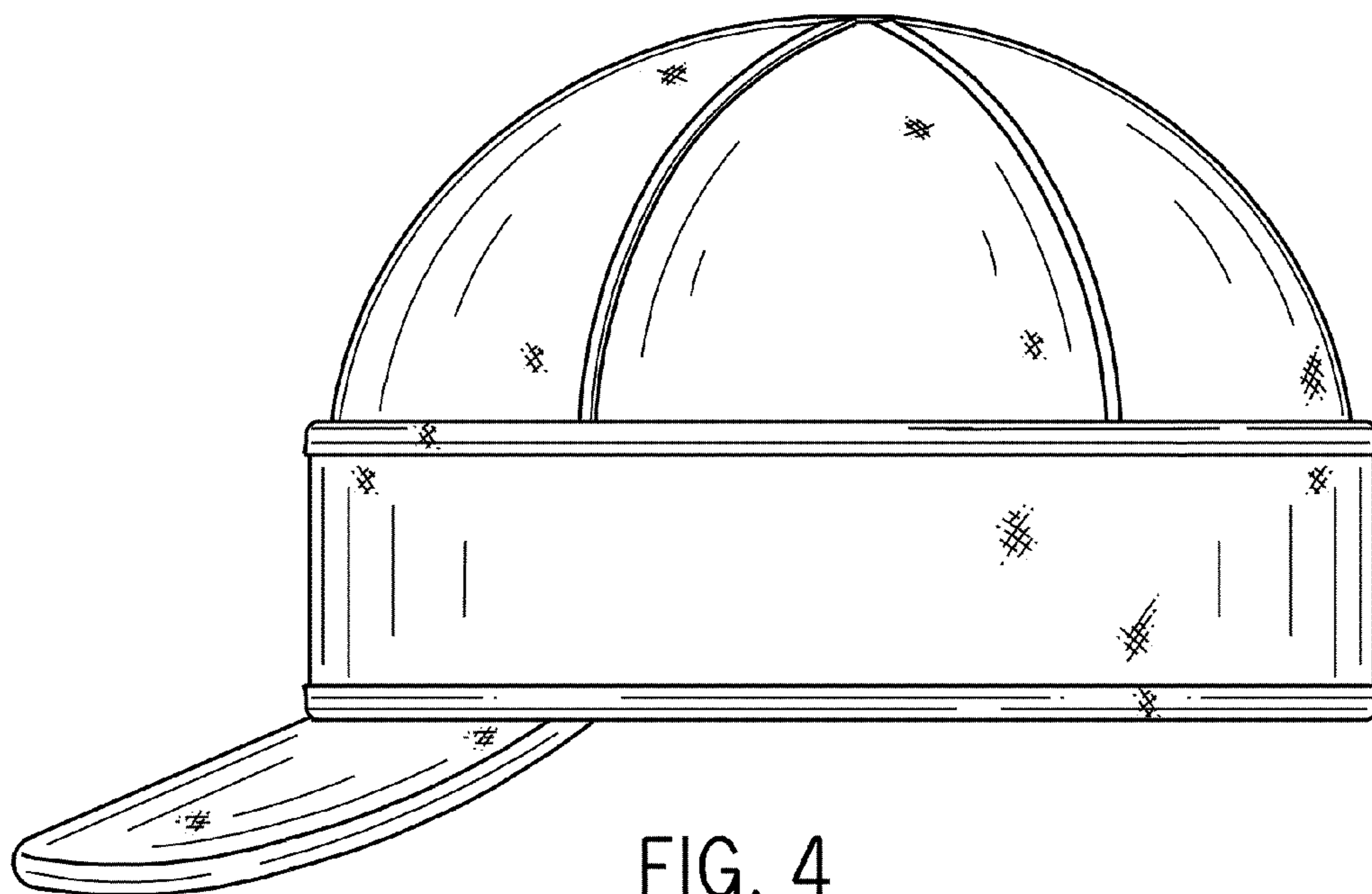


FIG. 4

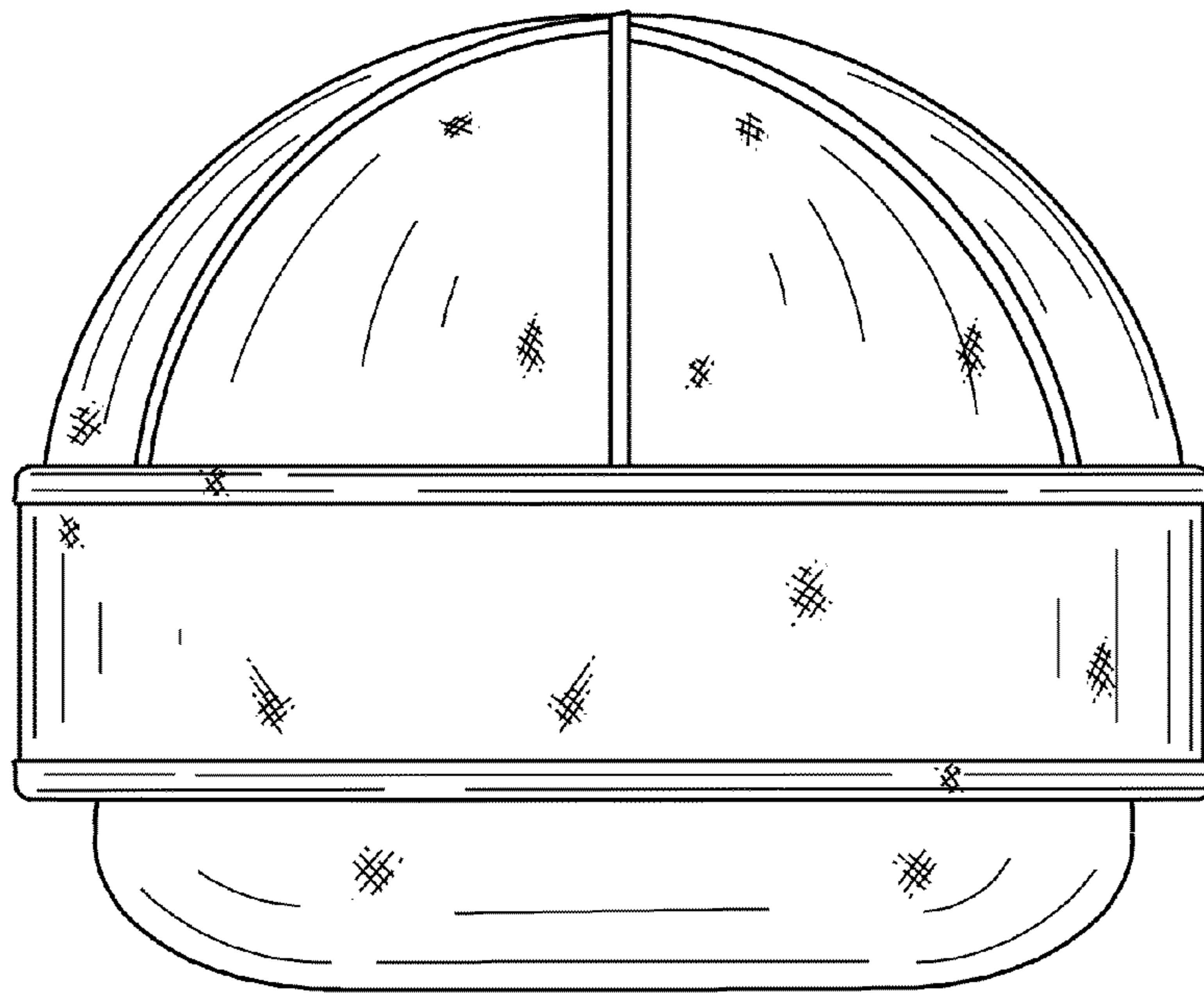


FIG. 5

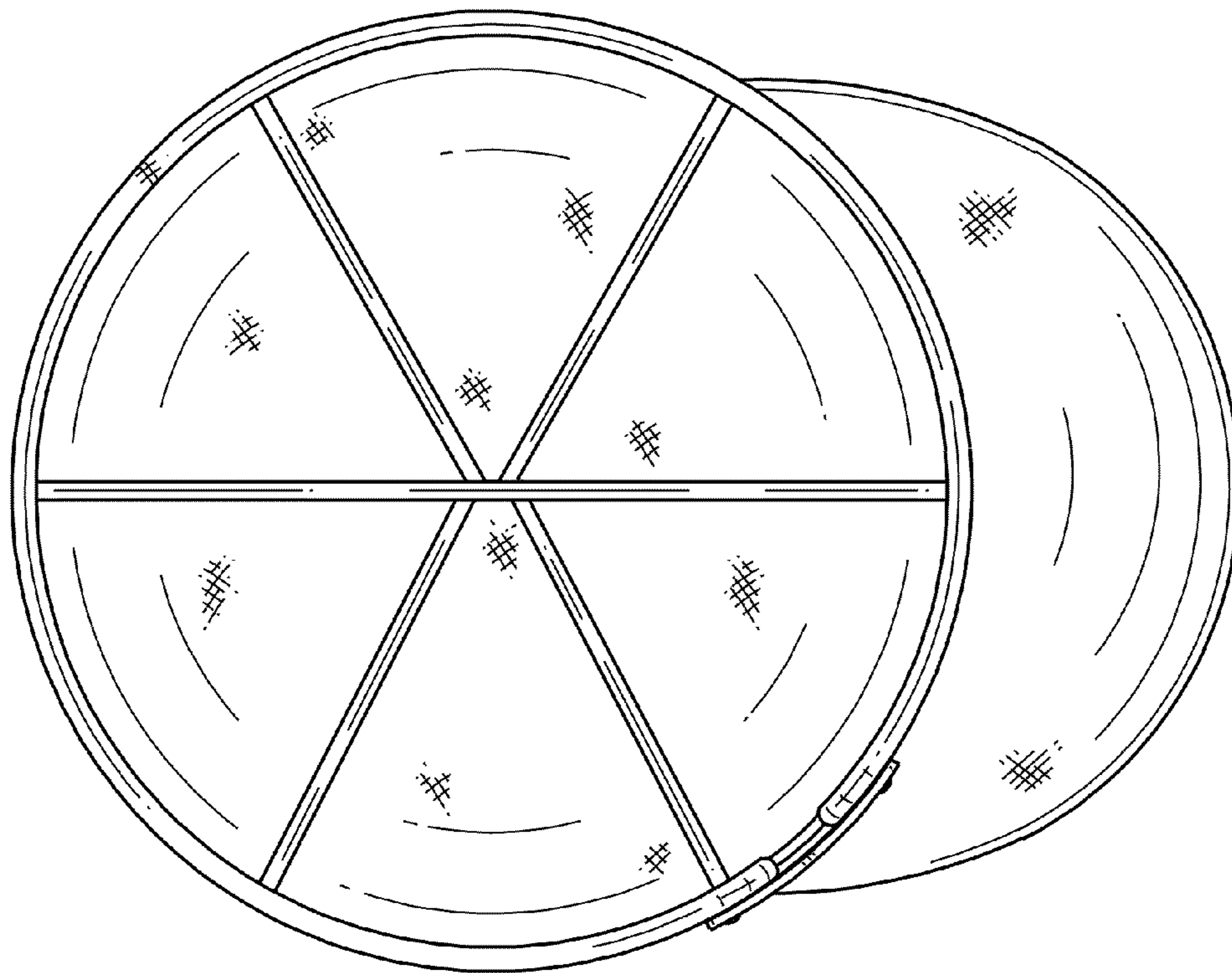


FIG. 6

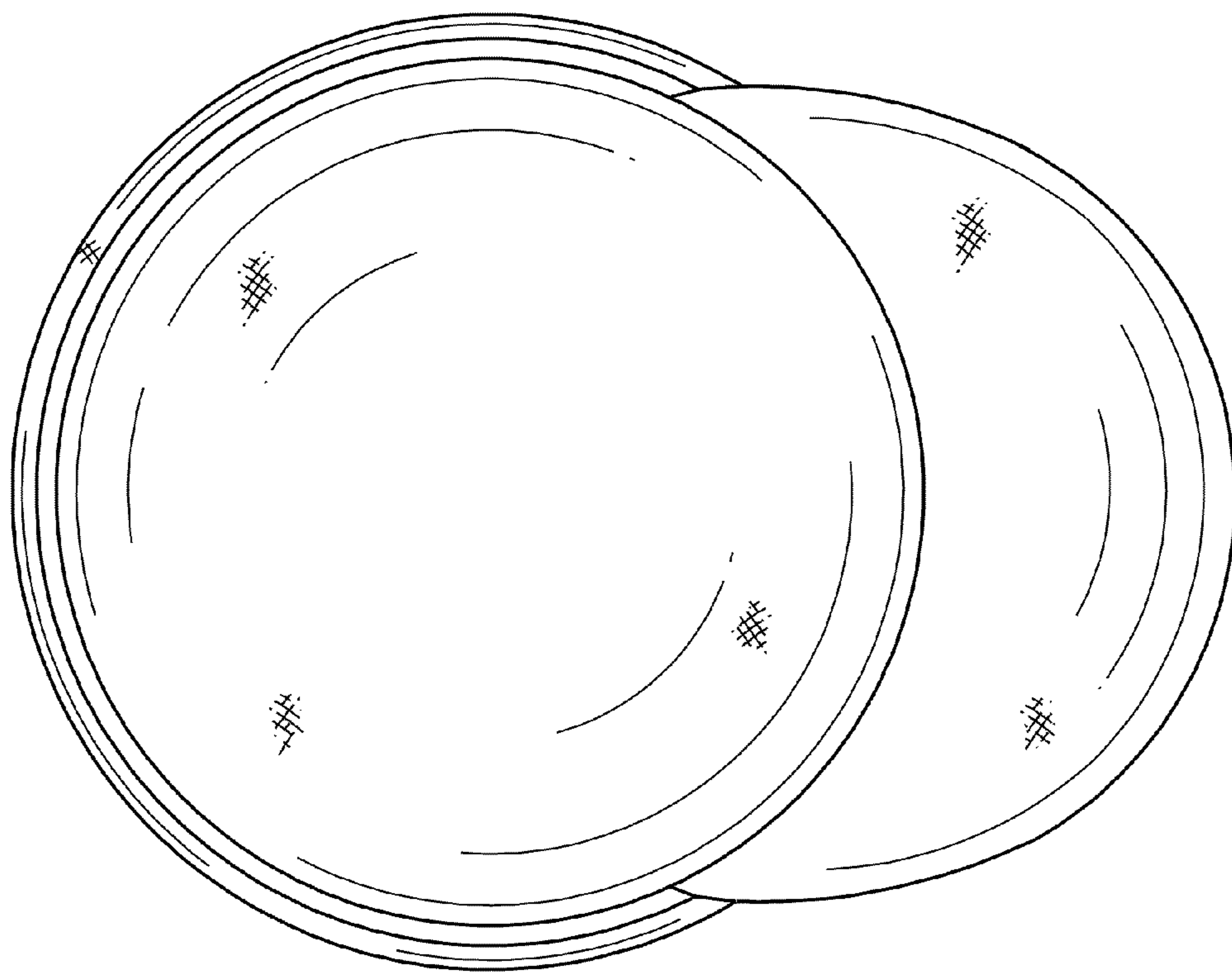


FIG. 7